



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

August 20, 2026

IGI Report Number

DESCRIPTION

SHAPE AND CUTTING STYLE

MEASUREMENTS

GRADING RESULTS

CARAT WEIGHT

COLOR GRADE

CLARITY GRADE

ADDITIONAL GRADING INFORMATION

POLISH

SYMMETRY

FLUORESCENCE

INSCRIPTION(S)

COMMENTS: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG818681736

Report verification at [igi.org](#)

PROPORTIONS

Medium To Slightly Thick (Faceted)

13%

47%

60%

63.7%

Pointed

Sample Image Used

CLARITY CHARACTERISTICS

KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

CLARITY

LABORATORY GROWN DIAMOND REPORT

August 20, 2026

IGI Report No LG818681736

MARQUISE BRILLIANT

12.60 X 5.97 X 3.80 MM

1.60 CARAT

E

VVS 2

EXCELLENT

EXCELLENT

NONE

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